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APPLICATION 1	VO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/801,825		03/09/2001	Yasuhiko Kojima	Yasuhiko Kojima P 276646		
909	7590	12/14/2004		EXAMINER		
PILLSB P.O. BOX		THROP, LLP	EL ARINI, ZEINAB			
MCLEA	N, VA 221	02		ART UNIT	PAPER NUMBER	
				1746		

DATE MAILED: 12/14/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

				1.1				
		Application No.	Applicant(s)	W				
	Office Action Consum	09/801,825	KOJIMA ET AL.					
	Office Action Summary	Examiner	Art Unit					
		Zeinab E. EL-Arini	1746					
Period f	The MAILING DATE of this communication or Reply	appears on the cover shee	et with the correspondence ad	dress				
THE - External control	IORTENED STATUTORY PERIOD FOR RE MAILING DATE OF THIS COMMUNICATION IN THE MAILING DATE OF THIS COMMUNICATION IN THE MAILING BATE OF SIX (6) MONTHS from the mailing date of this communication is period for reply specified above is less than thirty (30) days, a poperiod for reply is specified above, the maximum statutory per ure to reply within the set or extended period for reply will, by streply received by the Office later than three months after the med patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, ma reply within the statutory minimum o riod will apply and will expire SIX (6) atute, cause the application to become	ay a reply be timely filed If thirty (30) days will be considered timely MONTHS from the mailing date of this co	, mmunication.				
Status								
1)[\]	Responsive to communication(s) filed on 2	4 November 2004.		,				
2a)□	This action is FINAL . 2b) 🖂 T	This action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
5)□ 6)⊠ 7)□ 8)□	Claim(s) 1,3-9,17-19 and 21-30 is/are pend 4a) Of the above claim(s) is/are without Claim(s) is/are allowed. Claim(s) 1,3-9,17-19 and 21-30 is/are reject Claim(s) is/are objected to. Claim(s) are subject to restriction and ion Papers	drawn from consideration.						
	•							
	The specification is objected to by the Exam							
10)[_]	The drawing(s) filed on is/are: a) a							
•	Applicant may not request that any objection to t		• •					
11)	Replacement drawing sheet(s) including the com The oath or declaration is objected to by the			` '				
Priority ι	ınder 35 U.S.C. § 119							
a)l	Acknowledgment is made of a claim for fore All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the p application from the International Bure see the attached detailed Office action for a l	ents have been received. ents have been received in riority documents have be eau (PCT Rule 17.2(a)).	n Application No een received in this National S	Stage				
Attachmen	t(s)							
1) 🛛 Notic	e of References Cited (PTO-892)	4) Intervie	w Summary (PTO-413)					
2)	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 · No(s)/Mail Date	Paper N	No(s)/Mail Date of Informal Patent Application (PTO-	152)				
	1 1 400							

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DETAILED ACTION

Response to Arguments

The amendment and remarks filed 11/24/04 have been acknowledged and entered.

The final office action stated in paper No. 082404 has been withdrawn in view of applicants' remarks.

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 3-9, 17-19, and 21-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ivankovits et al. in combination with Nguyen et al. (US 2001/0009154 A1) and Senzaki et al. (6,090,960).

Ivankovits et al. as discussed supra in paper No. 082404 disclose a process comprises contacting the surface to be cleaned with an effective amount of cleaning agent comprising partially halogenated or fully halogenated linear or branched carboxylic acid, at a temperature sufficient

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to form volatile metal-complexes on the surface of the substrate to be cleaned. The volatile metal-complexes are sublimed from the surfaces of the substrate providing a clean, substantially residue-free surface. The reference teaches the cleaning agent, (claims 3, 4), the metal (copper), and the additive includes oxygen (claims 7, 8), The temperature (claim 18) and the pressure (claim 19). See the abstract, col. 2, lines 37-63, col. 2, line 67-col. 7, line 27, and the claims.

Ivankovits et al. as discussed supra do not teach cleaning the treatment chamber, and that the chamber is a component of one of a chemical vapor deposition equipment and a physical vapor deposition equipment, the heating step, the repeating and the confirming steps, and the copper material as claimed.

Nguyen et al. disclose a method for cleaning the interior surfaces of metal-organic chemical vapor deposition chamber. The reference discloses the chamber (claim 5), heating the wall, and the temperature (claims 28-30) as claimed. See the abstract, , the claims and the document in general.

It would have been obvious for one skilled in the art to use the process taught by Ivankovits et al. to clean the chemical vapor deposition equipment or the physical vapor deposition equipment of Nguyen et al.,

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because said vapor deposition equipment are made of quartz which is crystallized silicon oxide, and the substrates taught by Ivankovits et al. include, but are not limited to silicon, silicon oxide,----, which is functionally equivalent to the Nguyen et al. chamber and the substrate inside the chamber. This is also because Nguyen et al. also disclose cleaning the chamber and cleaning the substrate inside the chamber. One skilled in the art would repeat the steps to obtain optimum results. It would have been obvious for one of ordinary skilled in the art to use the heating step taught by Nguyen et al. in the Ivankovits et al. process to obtain the claimed process. This is because heating the wall of the chamber will reduce both condensation of the vaporized precursor and deposition on the chamber walls.

Nguyen et al. and the Ivankovits et al. do not disclose the copper material as claimed (claims 22-23).

Senzaki et al. disclose a method of applying chemical vapor deposition copper to integrated circuit substrates using a precursor as claimed. See the abstract, col. 4, lines 1-22, col. 7, lines 17-31, and claims 1, 10.

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It would have been obvious for one skilled in the art at the time applicants invented the claimed process to use the copper taught by Senzaki et al. in the Ivankovits in combination with Nguyen et al. to obtain the claimed process. This is because it is known in the art to use the copper material as claimed in the chemical vapor deposition chamber.

Response to Arguments

1. Applicant's arguments with respect to claims 1, 3-9, 17- 19, and 21- 30 have been considered but are moot in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Zeinab E. EL-Arini whose telephone number is (571) 272-1301. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr can be reached on (571) 272-1414.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Zeinab E. EL-Arini Primary Examiner Art Unit 1746

ZEE

12/09/04